

WEST Search History

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Hide?	<u>Set</u> <u>Name</u>	<u>Query</u>	<u>Hit</u> <u>Count</u>
		<i>DB=USPT; PLUR=YES; OP=ADJ</i>	
<input type="checkbox"/>	L5	US-5525542-A.did.	1
		<i>DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ</i>	
<input type="checkbox"/>	L4	L3 same (UV or ultraviolet)	9
<input type="checkbox"/>	L3	(semiconductor or substrate or workpiece) with ((group III) or GaN or AlN or InN or TiN or BN) with (resist or photoresist or residue)	243
		<i>DB=USPT,EPAB,JPAB,DWPI; PLUR=YES; OP=ADJ</i>	
<input type="checkbox"/>	L2	L1 and (dirt or photoresist or resist)	2
<input type="checkbox"/>	L1	4987008.pn.	2

END OF SEARCH HISTORY

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		<i>DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ</i>	
<input type="checkbox"/>	L30	L28 and (nitride same(Ga or Al or Tl or B))	70
<input type="checkbox"/>	L29	L28 and (Ga or Al or Tl or B)	170
<input type="checkbox"/>	L28	l26 and nitride	175
<input type="checkbox"/>	L27	L26 and (GaN or AlN or TiN or BN or AlGaN or AlInN or GaInN)	13
<input type="checkbox"/>	L26	((photoresist or resist or residue or organic) with (clean\$3 or remov\$3)) same ((UV or ultraviolet) with (oxygen or 'O.sub.2'))	763
<input type="checkbox"/>	L25	(photoresist or resist or residue or organic) same (clean\$3 or remov\$3) same (UV or ultraviolet) same (oxygen or 'O.sub.2')	2822
<input type="checkbox"/>	L24	(photoresist or resist or residue or organic) same (clean\$3 or remov\$3) same (UV or ultraviolet) same (oxygen or 'O.sub.2' or air)	4887
<input type="checkbox"/>	L23	L22 and oxygen	3
<input type="checkbox"/>	L22	Falkenstein-zoran\$.in.	7
<input type="checkbox"/>	L21	L20 and clean\$3	22
<input type="checkbox"/>	L20	Falkenstein\$.in.	186
<input type="checkbox"/>	L19	L18 and (GaN or AlN or TiN or BN or AlGaN or AlInN or GaInN)	11
<input type="checkbox"/>	L18	(photoresist or resist or residue or organic) with (clean\$3 or remov\$3) with (UV or ultraviolet) with (oxygen or 'O.sub.2' or air)	590
<input type="checkbox"/>	L17	L15 and nitride	18
<input type="checkbox"/>	L16	L13 and nitride	200
<input type="checkbox"/>	L15	L13 and (GaN or AlN or TiN or BN or AlGaN or AlInN or GaInN)	31
<input type="checkbox"/>	L14	L13 same (GaN or AlN or TiN or BN or AlGaN or AlInN or GaInN)	0
<input type="checkbox"/>	L13	(photoresist or resist or residue or organic) with (clean\$3 or remov\$3) with (UV or ultraviolet) with (oxygen or 'O.sub.2' or ozone or 'O.sub.3')	983
<input type="checkbox"/>	L12	L10 same (Ga or Al or Tl or B)	13
<input type="checkbox"/>	L11	L10 same (Ga or Al or In or Tl or B)	69
<input type="checkbox"/>	L10	L9 same nitride	108
<input type="checkbox"/>	L9	(resist or photoresist) same (UV or ultraviolet) same (oxygen or 'O.sub.2' or ozone or 'O.sub.3') same clean\$3	387
<input type="checkbox"/>	L8	l6 same (GaN or AlN or InN or TiN or BN or AlGaN or AlInN or GaInN)	1
<input type="checkbox"/>	L7	L6 same ((photo acid) or (photo-acid))	2
<input type="checkbox"/>	L6	(resist or photoresist) same (UV or ultraviolet) same (oxygen or 'O.sub.2' or ozone or 'O.sub.3')	2308

<input type="checkbox"/>	L5	(resist of photoresist) same (UV or ultraviolet) same (oxygen or 'O.sub.2' or ozone or 'O.sub.3')	0
<input type="checkbox"/>	L4	(resist of photoresist) same ((photo acid) or (photo-acid)) same (UV or ultraviolet) same (oxygen or 'O.sub.2')	0
<input type="checkbox"/>	L3	(resist of photoresist) same ((photo acid)or (photo-acid)) same (UV or ultraviolet) same (oxygen 'O.sub.2')	0
<input type="checkbox"/>	L2	(resist of photoresist) same ((photo acid)or (photo-acid)) same (UV or ultraviolet) same (ozone or 'O.sub.3')	0
<input type="checkbox"/>	L1	(photo acid) with (UV or ultraviolet) with (ozone or 'O.sub.3')	0

END OF SEARCH HISTORY